

3.46 PHOTONIC MATERIALS AND DEVICES

Lecture 16: Detectors—Part 1

Lecture

Semiconductor Photon Detectors

Photodetector \equiv transducer

$P_{\text{input}}(\text{optical}) \rightarrow I_{\text{output}}(\text{current})$

Attributes

- efficient
- low noise
- uniform spectral response
- high speed
- linear
- small, integrated, reliable, low cost

1) Photodetectors

a) **Human eye:** 10^8 dynamic range

Retina:

edge: 1.2×10^9 rod shaped cells
(low light levels)

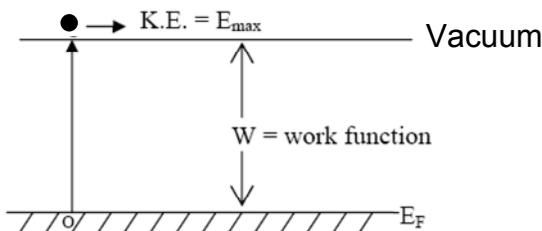
center: 6×10^6 cone shaped cells
(high light levels, color)

(3 sets: red, green, blue)

Cell diameter $\approx 2.5 \mu\text{m}$

b) **External photoemitters:**

A class of photodetectors called photoemissive in which electrons are emitted into a vacuum or gas.



$$E_{\text{max}} = h\nu - W(\text{metal})$$

$$E_{\text{max}} = h\nu - (E_g + \chi)(\text{semiconductor})$$

$$\chi = \text{electron affinity}$$

$$= E_{\text{vacuum}} - E_{\text{CB}}$$

Notes

Supplemental reading:

1. Fundamentals of photonics ch. 17
2. Burle – Electro-Optics Handbook §10
can be downloaded for free from:
www.burle.com/cgi-bin/byteserver.pl/pdf/Electro_Optics.pdf

Lecture

Photoemissive “surfaces”

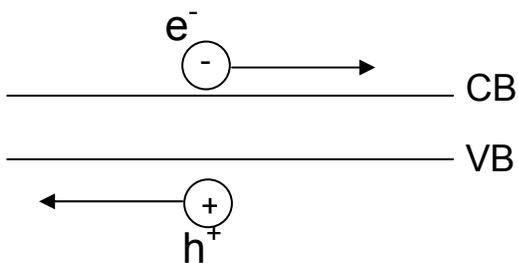
metals → visible $\eta_i \approx 10\%$
 semiconductors → IR $\eta_i \approx 0.1\%$

Photomultipliers

- A series of dynodes yields secondary electrons ($M \approx 10^6$) by field acceleration of photoelectron

$$I = \frac{\Delta Q}{\Delta \tau} = \frac{\phi \cdot A \cdot t \cdot \eta_i \cdot \text{gain} \cdot e}{RC} = 10^{-8} \text{ A/photon}$$

c) Internal photoemitters:



- generation
- transport
- multiplication ?

1) Quantum efficiency

$$\eta = (1-R) \cdot \xi \cdot [1 - \exp(-\alpha d)]$$

Charge collection efficiency

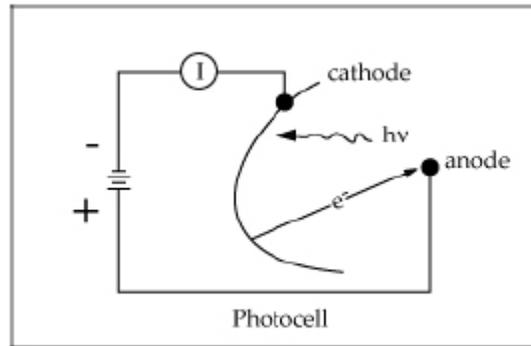
Fraction of photons absorbed in active region

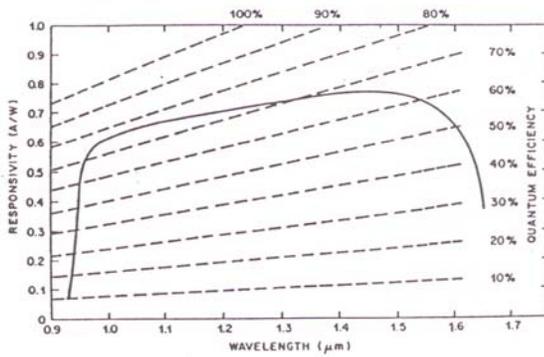
2) Responsivity

$$R = \frac{\eta e}{h\nu} = \eta \cdot \frac{\lambda}{1.24} \text{ A/W}$$

varies linearly with η , λ

Notes





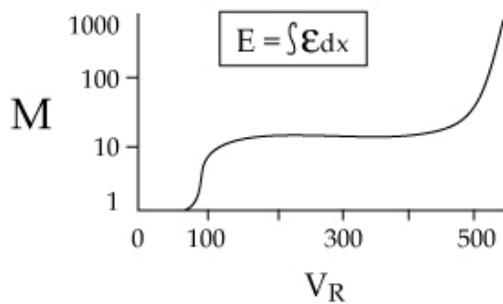
R cutoffs:

long λ : $\lambda_g = \frac{E_g}{hc}$

short λ : surface recombination

3) Gain

$$\text{gain} = \frac{\# \text{ charges}}{\# \text{ photoelectrons}} = \frac{Q}{e} = \frac{Q}{\phi}$$



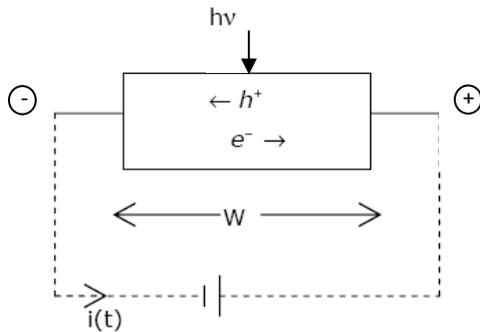
4) Response Time

Transit time (τ_{tr}) \equiv time for photocarriers to reach electrodes

Ramo's theorem:

$$i(t) = -\frac{Q}{W} v(t)$$

Lecture



drift velocity: $\vec{v}_d = \mu \vec{E}$

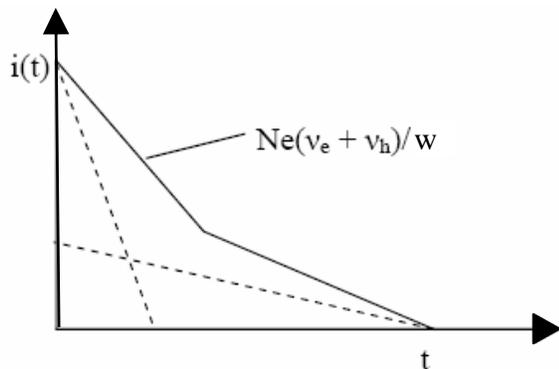
[↑ same justification ↓]

electric field: $\vec{E} = V/w$

⇒ since each carrier moves $\langle w/2 \rangle$, the effective charge moving in the external circuit is e not $2e$.

- a. usually $v_h < v_e$
 - transit time spread
 - τ_{tr} determined by slowest carrier

$$\Rightarrow \Delta t \approx \frac{w}{v_h}$$



- b. $\tau_{RC} = R \cdot C$ of detector circuit
 - heavy doping ($R \downarrow$, $C \uparrow$)
 - small device area ($C \downarrow$)
- c. w collection length
 $w_{\text{junction}} \ll w_{\text{photoconductor}}$

Notes

5) Photoconductor

$$\Delta\sigma = e\Delta n(\mu_e + \mu_h)$$

$$= e\eta\tau \frac{\Phi}{w \cdot A} (\mu_e + \mu_h)$$

$$i_p \approx e\eta \frac{\tau}{\tau_{tr}} \Phi \quad \tau_{tr} \approx \frac{w}{v_e}$$

$$v_h \ll v_e$$

τ = recombination lifetime

$\frac{\tau}{\tau_{tr}}$ = fraction of e^- collected

$e\eta\Phi$ = generation rate/unit volume

Typical values

$w = 1 \text{ mm}$ \Leftarrow slow

$v_e = 10^7 \text{ cm/s}$

$\tau_{tr} \geq 10^{-8} \text{ s}$

If $\tau \ll \tau_{tr}$, τ = response time

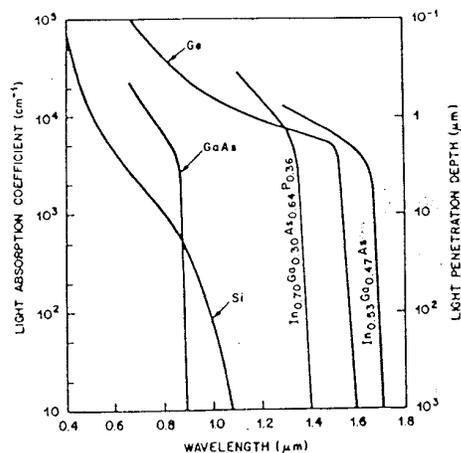
\therefore fast \equiv low R

6) Photodiodes

PIN: positive-intrinsic-negative

APD: avalanche photodiode

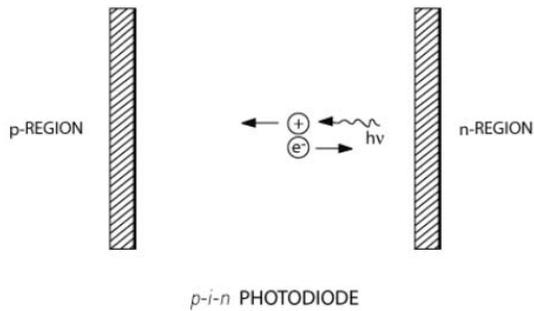
$\lambda = 1.3 \text{ }\mu\text{m}$ or $\lambda = 1.5 \text{ }\mu\text{m}$



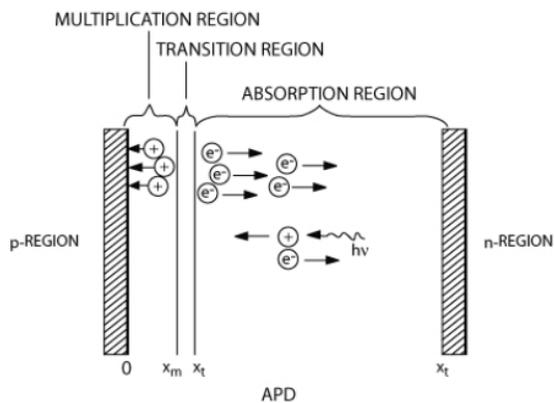
InP substrateInGaAsP $\lambda = 1.3 \mu\text{m}$ InGaAs $\lambda = 1.55 \mu\text{m}$ **would like to have high α/β** α = ionization multiplication rate for e^- β = ionization multiplication rate for h^+

Bulk GaAs $\Rightarrow \frac{\alpha}{\beta} = 2$

50 layer GaAs/AlGaAs $\Rightarrow \frac{\alpha}{\beta} = 8$



(a)



(b)

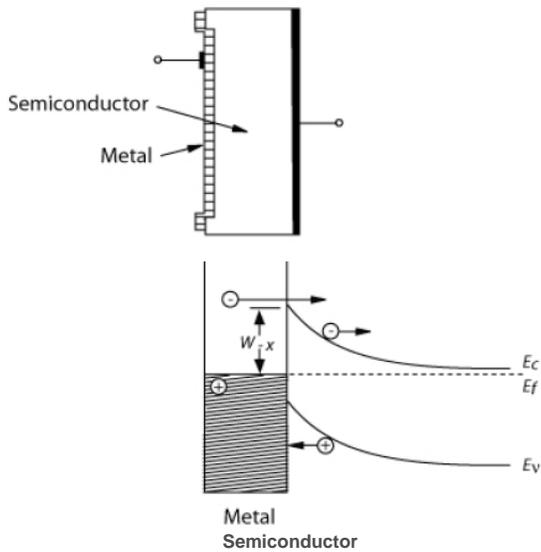
PIN

- easy to fabricate
- shot noise (thermal leakage)

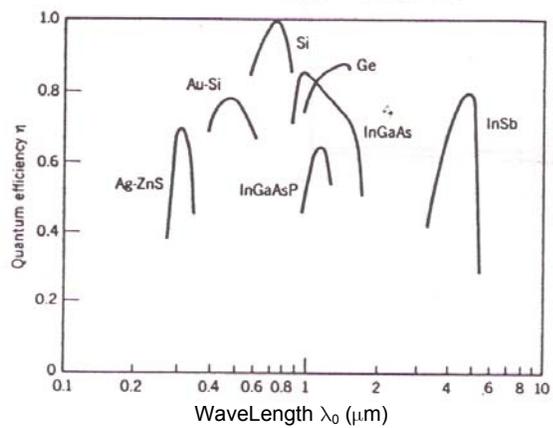
APD

- high **gain bandwidth** product
- heavily doped n-InP for M
- gain noise (M statistics)

7) Schottky Barriers Photodiode



8) Relative performance



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9) Materials for IR detectors

NIR	SWIR (Short Wave)	MIR (Mid IR)	FIR (Far or long wave IR)
0.6-1.1 μm	1.1-2.5 μm	3-5 μm	8-12 μm
Si, Ge	PbS, InGaAs (0.9-1.7 μm), Ge (0.7-1.85 μm)	InSb, HgCdT	Ge

*wavelength range is practical detector values from various manufacturers